

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	0	(method and fabricating and composite and capacitor and semiconductor adj die and depositing and lower adj interconnect adj metal adj layer and forming and upper adj electrode and a lower adj capacitor adj over and patterning adj lower adj interconnect adj metal adj layer and form adj lower adj electrode and depositing adj interlayer adj dielectric adj layer adj over).clm.	US-PGPUB	OR	ON	2008/01/21 20:33